技术及应用

等熵稀疏靶的制备及靶参数精密测量

叶君建, 何钜华, 傅思祖, 黄秀光, 谢志勇

上海激光等离子体研究所,上海 201800

收稿日期 2008-6-26 修回日期 2008-7-30 网络版发布日期: 2008-9-20

摘要 本工作研究等熵稀疏靶的制备工艺和靶参数的测量方法。采用精密激光加工工艺将AI、Au、Ag、Cu、Zn等高纯金属薄膜切割成百微米量级宽度的窄条,再结合精密微装配技术获得应用于状态方程实验所需的等熵稀疏靶。运用白光干涉仪对等熵稀疏靶进行参数精密测量。将等熵稀疏靶运用到"神光Ⅱ"上进行实验打靶,并获得优质的实验图像。

关键词 等熵稀疏; 靶; 激光; 状态方程

分类号 TL62

Fabrication and Measurement of Isentropic Release Targ et

YE Jun-jian, HE Ju-hua, FU Si-zu, HUANG Xiu-guang, XIE Zhi-yong

Shanghai Institute of Laser and Plasma, Shanghai 201800, China

Abstract he fabrication and measurement of isentropic release targets were described. The A l, Au, Ag, Cu and Zn thin foils were cut to hundred micron by apparatus of laser. They are fabrica ted to isentropic release targets using in the laser equation of state experiments by the assembly. T he parameters of targets were measured by NT1100 profiling system. The isentropic release targets were used in 'SG II' experiments and good images were obtained.

Key words <u>isentropic</u> <u>release</u> <u>_ target</u> <u>_ laser</u> <u>_ equation</u> <u>of</u> <u>state</u>

DOI

扩展功能

本文信息

- ► Supporting info
- ▶ [PDF全文](2301KB)
- ▶[HTML全文](0KB)
- ▶参考文献

服务与反馈

- ▶ 把本文推荐给朋友
- ▶ 文章反馈
- ▶浏览反馈信息

相关信息

- ▶ <u>本刊中 包含"等熵稀疏;靶;激</u> 光;状态方程"的 相关文章
- ▶本文作者相关文章
- 叶君建
- 何钜华
- 傅思祖
 - 黄秀光

谢志勇

通讯作者